## NOTES:

1. SUBSTRATE:

**FUSED SILICA** 

## 2. SUFRACE S2 TO BE PARALLEL TO S1 TO WITHIN <3 ARCMIN

3. COATING (APPLY ACROSS CLEAR APERTURE)

S1: R(abs): >99% @ 532nm R(abs): >99% @ 1064nm T(abs): >70% @ 266nm

S2: R(abs): <1.0% @ 266nm

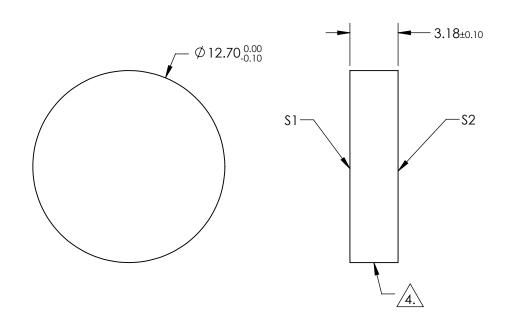
DAMAGE THRESHOLD, PULSED:

S1: 5 J/cm<sup>2</sup> @ 532nm, 20ns, 20Hz 7.5 J/cm<sup>2</sup> @ 1064nm, 20ns, 20Hz 2.5 J/cm<sup>2</sup> @ 355nm, 20ns, 20Hz

S2: 7.5 J/cm<sup>2</sup> @ 355nm, 20ns, 20Hz



5. ROHS COMPLIANT



## FOR INFORMATION ONLY: DO NOT MANUFACTURE PARTS TO THIS DRAWING

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE DIMENSIONS ARE FOR REFERENCE ONLY

	\$1	\$2		
SHAPE	PLANO	PLANO		
SURFACE QUALITY	10 - 5	COMMERCIAL POLISH		
CLEAR APERTURE	Ø11.43	N/A		
SURFACE FLATNESS	λ/10	N/A		
BEVEL	PROTECTED AS NEEDED	PROTECTED AS NEEDED		

<b>Edmund Opt</b>		<b>Edmund Optic</b>	S®		
I IHIKU ANGLE (A) C     TITLE		12.7mm Dia., 355nm T, 532 & 1064nm Thin Harmonic Separator	R 45°		
)	ALL DIMS IN	mm	DWG NO	29052	SHEET 71 OF 86